# Equipment

# EQUIPMENT AVAILABLE THROUGH ANML AT BOISE STATE UNIVERSITY

For more information and/or to learn how to access equipment email Prof. David Estrada at daveestrada@boisestate.edu.

## TRANSPORT CHARACTERIZATION LABORATORY

- 3 Advanced DC & sub-RF Electrical Characterization Systems (Computer Controlled)
- Keithley 4200, 100 aA resolution, dual-channel pulse generator pulse I-V (100 ns rise/fall time and 40-150 ns pulse width, duty cycle: 0.01 to 99% 0-5V, quiescent point pulsing), switch matrix, 20Hz-1MHz C-V, built-in 2-channel 750MHz digital o-scope, Quasi-static CV
- Agilent 4156C semiconductor characterization system with switch matrix
- 3 HP 4284A LCR meters (20Hz to 1MHz)
- Probe Stations: 1 closed-cycle cryogenic with actively cooled probes (5.5 to 450 K), 1 high temperature (673K), 2 room temperature
- Low Noise Spectroscopy System
- Agilent 4294A precision impedance analyzer
- 2 SRS SR830 dual phase and SRS SR810 single phase lock-in amplifiers
- 1GHz 4 channel 4GSamples/s Mixed Signal oscilloscope
- ~25 Cascade micromanipulator probes (4 high temperature)

## Advanced Nanomaterials and Manufacturing Laboratory

## <u>Surface Science</u>

- Bruker nanoIR3S AFM
  - Nanoscale IR Spectroscopy
    - s-SNOM providing near field amplitude and phase images and spectra
    - Resonance Enhanced AFM-IR mode
    - Tapping AFM-IR spectroscopy & chemical imaging mode
    - Point Spectroscopy & IR chemical mapping capability
    - HotSPOT enabled selection of any point or series of points within the AFM image to obtain localized nanoIR spectra
    - IR imaging at a fixed wavenumber of interest; ratio spectral images at user defined wavenumbers
    - Export AFM-IR spectra to optional external IR databases for identification of unknown materials
    - · Analysis Studio software package for acquisition, control, analysis & export
    - Atomic Force Microscopy
      - X,Y scanner with range of 50µm by 50µm using closed loop linearization for precise positioning performance
      - Standard AFM modes supported: Tapping, Phase Imaging, Contact, Lateral Force, Force Curves, Force Modulation, EFM/MFM mode
      - Integrated bright-field optical microscope with a 10X objective for viewing the sample and probe with a resolution of 1.5 microns
      - Computer controlled XY sample positioning stage, 8.0 mm travel in X, 8.0mm travel in Y
        - Analysis Studio software package for acquisition, control, and analysis
    - Mid-IR Laser Source for s-SNOM and AFM-IR Broadband Spectroscopy
      - Femtosecond based laser source with a spectral range of approx. 2.5µm to

- 14µm wavelength (700 4,000cm-1)
- For use with s-SNOM & AFM-IR technique. Configuration includes:
- Includes additional nanoIR laser integration module & associated optics for broadband spectroscopy operation for complete operation
- Provides s-SNOM spectroscopy across a spectral range of 700 to 4,000cm<sup>-1</sup>
- Provides s-SNOM imaging in the range of <700->2,000 cm<sup>-1</sup>
- Provides AFM-IR spectroscopy and imaging in the range of 700-2,000cm<sup>-1</sup>
- AM-nIR-TA Thermal Analysis
  - Transition Temperature Microscopy (TTM)
- o Relative thermal conductivity/temperature mapping (SThm)
- Horiba Scientific LabRAM HR Evolution Raman Microscope
  - 442 nm, 532 nm, and 633 nm (visible) excitation wavelengths available
    - 325 nm (UV) excitation wavelength possible with additional laser line filter
    - 10x, 20x, 50x, and 100x bright field objectives
      - LWD 20x objective also compatible with DIC, fluorescence, and polarized light
  - o 600 and 1800 line/mm holographic diffraction gratings blazed for 500-600 nm
  - 0 0.8 m monochromator equipped with confocal pinhole
  - o Thermoelectrically cooled Si CCD array (256 x 1024) detector
  - $\circ$  ~1 µm lateral resolution at 633 nm (~500 nm maximum resolution with UV excitation)
  - o 80 x 100 mm motorized stage for point by point Raman mapping
  - $\circ$  µm step size with ± 1 µm repeatability and accuracy
  - DuoScan optics for high speed, high resolution mapping
- PHI VersaProbe II Scanning XPS Microprobe
  - Scanned, micro-focused, monochromatic x-ray beam
  - X-ray beam induced secondary electron imaging
  - Dual beam charge neutralization
  - Large area XPS

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- Micro-area XPS
- Chemical state imaging with 128 data channels
- Sputter depth profiling
- Floating column argon ion gun
- Computentric Zalar rotation
- o Angle dependent XPS
- Five axis automated sample manipulator
- 25 mm and 60 mm diameter sample holders
- Zeiss Axio Imager M2m Materials Microscope
  - Transmitted Light
  - Reflected Light
  - DIC imaging
  - Phase contrast imaging
  - Polarization imaging
  - Automated X-Y-Z mechanical stage
  - Colibri fluorescence imaging
  - Axiocam 105 Color Camera
  - 10X thru 100X objectives
  - ZenCore Analysis Software
- Biolin Scientfic T200-Auto3 Attension Theta Optical Tensiometer with Automatic XYZ stage and Pipette Dispenser
  - Sessile Drop Contact Angle Measurements
  - Dynamic Contact Angle

- o Surface Free Energy Calculations
- o Surface and Interfacial Tension Measurements
- o Topography Attachment for Surface Roughness Analysis
- Biolin Scientfic Attension Theta Lite Tensiometer
  - o Sessile Drop Contact Angle Measurements
  - Dynamic Contact Angle
  - Surface Free Energy Calculations
  - o Surface and Interfacial Tension Measurements
- QEA PIAS-II Image Analysis System with Field Verification Target.

## 2-dimensional Materials Synthesis

- Aixtron 2D Cold Coupled Showerhead Metalorganic Vapor Phase Epitaxy (MOVPE) System
  - 12 metalorganic sources with 12 Epison 5 controllers
  - $_{\odot}$  5 process gasses (H<sub>2</sub>S, H<sub>2</sub>Se, NH<sub>3</sub>, CH<sub>4</sub>, H<sub>2</sub>)
  - $\circ$  N<sub>2</sub> and Ar carrier gasses
  - o 1400 C 3" x 2" CCS Tungsten 3-zone furnace with Graphite Reactor
  - Full flow and stop flow modes
  - Argus top-side temperature control and Laytec EpiTT® 3W In-situ process monitoring
- PlanarTech planarGROW-3S-TMD 3-zone Thermal Chemical Vapor Deposition (CVD) System
  - 3" (75mm) OD Quartz Tube
  - One (1) x 3-Zone Fixed Furnace
    - Max. 1,100°C
    - 100/300/100mm Heating Zones
  - Three (3) MFCs for Ar, H2 & CH4
  - o LN2 Cold Trap & H2 Dilution Kit
  - 250l/m Dry Scroll Pump
  - Auto-Pressure Control
  - o 1000 Torr Capacitance Manometer
  - Motorized Throttle Valve
  - o Fully Automated PC Control w/ LabVIEW Front End
  - 2 solid source heating kits
- Custom built quartz tube variable pressure chemical vapor deposition system with 4 inlet gases and up to two solid-source precursors.
- MTI 2" Alumina Tube furnace with inert gas inlet and vacuum compatible (qty. 2)
  - Vacuum or inert gas environment
  - $\circ$  5 10°C/min heating rate
  - 23°C 1500°C capability

#### High Performance Computing

- COMSOL Multiphysics FEM software
  - Floating Network License (FNL) for one (1) concurrent user (qty. 3)
  - AC/DC Module for use with COMSOL Multiphysics, (FNL qty. 1)
  - Acoustics Module for use with COMSOL Multiphysics, (FNL qty. 1)
  - CAD Import Module for use with COMSOL Multiphysics (FNL qty. 1)
  - CFD Module for use with COMSOL Multiphysics (FNL qty. 1)
  - Chemical Reaction Engineering Module for use with COMSOL Multiphysics (FNL qty. 1)
  - Electrochemistry Module for use with COMSOL Multiphysics (FNL qty. 1)
  - Heat Transfer Module for use with COMSOL Multiphysics (FNL qty. 1)
  - Material Library for use with COMSOL Multiphysics (FNL qty. 1)

- MEMS Module for use with COMSOL Multiphysics (FNL qty. 1)
- Microfluidics Module for use with COMSOL Multiphysics (FNL qty. 1)
- Porous Media Flow Module for use with COMSOL Multiphysics (FNL qty. 1)
- RF Module for use with COMSOL Multiphysics (FNL qty. 1)
- Semiconductor Module for use with COMSOL Multiphysics (FNL qty. 1)
- Structural Mechanics Module for use with COMSOL Multiphysics (FNL qty. 1)
- Wave Optics Module for use with COMSOL Multiphysics (FNL qty. 1)

## Nanoink/Nanofluid Synthesis

- 4 fume hoods equipped with hot plates, mixers, and various glassware for nanomaterials synthesis through chemical reactions.
- Branson 2800 variable temperature ultra-sonicator
- 6 Eppendorf adjustable volume pipettes
- 6 Fisherbrand mini-centrifuges
- Mettler Toledo Analytical Balance
- Thermo Scientific Legend Micro 21 Microcentrifuge
- Think Planetary Centrifuge
- Heraeus Megafuge 8 with TX-150 Cell Cult Pkg (8 x 50 ml)
- Thermo Scientific Heratherm Programmable Gravity Convection Oven
- Beckman/Coulter Optima XE-90 Ultracentrifuge
  - o 90,000 maximum RPM
  - o 694,000g
  - $\circ$  0 40 °C temperature range
  - SW41-Ti swing bucket rotor with 90 mL capacity
- Retsch EMAX High Energy Ball Mill System (qty. 2)
  - Max 2000 RPM
  - Water cooled for temperature controlled grinding
  - Operation with 2 grinding jars
  - Stainless steel, chrome steel, and zirconia jars and media
- Silverson L5MA Stand Mixer (qty. 2)
  - High shear mixer for particle dispersion
  - Capacity from 1 ml to 12 liters
  - Maximum speed of 6000 rpm under full load
  - Multiple workheads for different application including: disintegrating head, emulsor screens, particle size reduction, and axial flow heads.
- Biocomp Instruments Nano Gradient Fractionator/Former
- QSonica Q125 probe-tip ultra-sonicator
- QSonica Q700 probe-tip ultra-sonicator
- Buchi Corporation Rotavapor R-100 Rotary Evaporator with I-100 Controller
- Labconco FreeZone 4.5L Benchtop Freeze Dryer w/PTFE Coated SS 12 Port Drying Chamber (-105 °C)
- KrosFlo KR2i Fully Automated Tangential Flow Filtration System
  - $\circ$  10 mL 15 L volume capacity
  - $\circ$  100 cm<sup>2</sup> to 5000 cm<sup>2</sup> filtration area
  - MBraun UniLab Pro PS Glovebox System
    - 3 glove system
    - Copper catalyst and carbon filter work together to provide an in-box atmosphere of O<sub>2</sub> and H<sub>2</sub>O <1ppm</li>
    - o Equipped with scale and hot plate
    - Capable of air sensitive chemical reactions, with top purge valve to snorkel hood for easy

#### environmental purge and generated gas removal

Nanoink/Nanofluid/Nanomaterial Characterization

- Brookfield Engineers Lab DV3TLV Rheometer
- Rheosense microVISC and Temperature Controlled Rheometer
- Brookfield Engineers Lab DVNext Cone/Plate Rheometer
- Brookhaven NanoBrook Omni Submicron Particle Sizer (DLS) and Zeta Potential Analyzer (PALS)
  - $\circ$  < 0.3 nm to 10 um
  - $\circ$  15°, 90°, 173° measurement angles
  - Temp. control -5 to 110 C
  - $\circ$  Sample Cells 10 uL 3 mL
  - Concentration Range 0.1 ppm to 50 mg/mL (sample dependent)
- Netzsch STA 449 F5 Jupiter Simultaneous Thermal Analyzer
  - RT to 1600°C
  - $\circ$  TGA resolution: 0.025 µg
  - Heating and Cooling Rate: 0.001 K/min to 50 K/min
  - $\circ$  DSC resolution: < 1  $\mu$ W
  - Mass Range: 1 u to 300 u
  - Atmospheres: inert, oxidizing, static, dynamic, vacuum
- Netzsch STA 449 F1 Jupiter Simultaneous Thermal Analyzer Coupled to Netzsch QMS 403C
  - and Bruker Tensor 27 FTIR
    - RT to 2000°C
    - $\circ$  TGA resolution: 0.025 µg
    - o Heating and Cooling Rate: 0.001 K/min to 50 K/min
    - $\circ$  DSC resolution: < 1  $\mu$ W
    - Atmospheres: inert, oxidizing, static, dynamic, vacuum
    - Mass Range: 1 u to 300 u
    - Electron Impact Ion Source
    - $\circ~$  Quartz-glass Capillary 75  $\mu m$  diameter, in metal tube, with supply coil, easily exchangeable
    - $\circ$  mid-IR source 4000 to 400 cm<sup>-1</sup>
    - $\circ$  Resolution: <1 cm<sup>-1</sup>
    - KBr pellet holder and press

# Physical/Chemical Property Characterization

- Quantum Design Physical Property Measurement System
  - DC Resistivity, AC Transport (AC Resistivity, Hall Coefficient, I-V Curve, & Critical Current for superconductors) under user controlled magnetic field, pressure, gas composition, and temperature.
  - Magnetic field may be programmed anywhere from 0 to +/- 70,000 Oersted and the sample's temperature can be programmed from 1.9 to 400 K.
- Janis CCS-400H/204N high temperature, optical cryostat system with sample in vacuum (10 K to 800 K)
  - 19 pin electrical feed-through
  - LakeShore Model 335 temperature controller
  - Model TS-75-D turbo-pumping station
  - OFHC copper optical sample holder
  - Keithley 6221/2182A Current Source and Nanovoltmeter Combo
    - $\circ$   $\,$  Measure resistances from  $10n\Omega$  to  $100M\Omega$
    - Synchronized current-pulsed source and measurement times as short as 50µs

- o Delta mode current reversal, resistance measurement technique
- Differential conductance measurement technique
- Current Sourcing:
  - DC: ±10fA 100mA
  - AC: 4pA p-p 200mA p-p
- Voltage Measurement:
  - 1nV sensitivity
  - 15nVp-p noise at 1s response time, 40–50nV p-p noise at 60ms
  - Dual channels
  - Built-in thermocouple linearization and cold junction compensation
- BioLogic SP-50 Potentiostat
  - Single channel potentiostat
    - Voltage
      - Control voltage:  $\pm 10$  V
      - Voltage resolution:  $5 \mu V$  on 200 mV range
      - Compliance: ±10 V
    - Current
      - Current ranges:  $800 \text{ mA to } 10 \mu \text{A}$
      - Maximum current: ±800 mA
      - Current resolution: 0.760 nA
  - o EC Lab Software
- SRS 830 SDP Lock-in Amplifier (qty. 3)
  - 2 nV minimum voltage sensitivity
  - Single-ended or differential voltage input
  - Digital signal processing
  - 50/60 and 100/120 Hz notch signal filters
  - $\circ$  Extended dynamic reserve >100 dB
  - Internal or external references
  - Reference channel
    - 1 mHz 102 kHz frequency range
    - TTL (rising or falling edge) or sine wave input
    - 0.01° phase resolution
- Omega Ice Point Calibrator High Precision Base Model TRCIII
  - On-site calibration of temperature sensors
  - Uniform thermocouple junction temperatures
  - Compensate for thermocouple effect
  - Up to 6 probes
  - Six reference wells at precisely 0°C
  - Alternates freezing and thawing of the ice accurately maintains a 0°C
    - Automated (sensed by expansion of bellows)
    - Maintained at ±0.1°C
    - Stability of  $\pm 0.04^{\circ}$ C for constant ambient
- Keithley 2612B Dual-Source Measurement Unit (qty. 2)
  - Power: 200 W Pulse, 30 W DC / Channel
  - $\circ$  Current Source / Measure:  $\pm 100$  fA min;  $\pm 10$  A Pulse,  $\pm 1.5$  A DC
  - $\circ$  Voltage Source / Measure:  $\pm 100 \text{ nV min}$ ;  $\pm 200 \text{ V max}$
  - o Comms: IEEE-488; USB 2.0, LAN/LXI-C; RS-232
- Keithley 6500 Digital Multimeter
  - 0 15 measurement functions including capacitance, temperature, and digitizing
  - $\circ$  Expanded measurement ranges include 10 pA to 10 A and 1  $\mu\Omega$  to 100 M $\Omega$

- Large 5-inch (12.7 cm) multi-touch capacitive touchscreen with graphical display
- Large internal memory; store up to 7 million readings
- SRS-DS345-30 MHz Function/ARB Generator
  - $\circ$   $-1~\mu\text{Hz}$  to 30.2 MHz frequency range
  - $\circ$  1  $\mu$ Hz frequency resolution
  - Sine, square, ramp, triangle & noise
  - Phase continuous sweeps
  - AM, FM, PM & burst
  - o 16,300 point arbitrary waveforms
  - o 10 MHz reference input
  - RS-232 and GPIB
- SRS-560 Low-noise voltage preamplifier
  - $\circ$  4 nV/ $\sqrt{\text{Hz}}$  input noise
  - $\circ \quad 1 \text{ MHz bandwidth} \\$
  - Variable gain from 1 to 50,000
  - AC or DC coupled
  - Two configurable signal filters
  - Differential and single-ended inputs
  - Line or battery operation
  - RS-232 interface
- Krohn-Hite Model 3382 0.1 Hz to 200 kHz Dual Channel 8-Pole Filter
  - Two Independent Filter Channels
  - One Band-Pass Channel
  - o Attenuation: 48dB/Octave
  - Filter Modes: Low-Pass and High-Pass
  - Response: Butterworth and Bessel
  - Input: Differential and Single-Ended
  - Input Gain: 0dB to 50dB in 10dB steps
  - Output Gain: 0dB to 20dB in 0.1dB steps
  - Battery Operation Option
- NI PXIe-1071 3 slot Chassis
  - o 2.2 GHz Celeron 1020E Dual Core Processor and Control Board
  - X Series Data Acquisition: 2 MS/s, 16 AI, 24 DIO, 2 AO
  - o 25 kS/s, 24-Bit, 8-Channel PXI Strain/Bridge Input Module
- TDK Lambda Programmable Power Supply
  - o 750 W
  - $\circ$  85 265 Vac Continous
  - Max Voltage Output: 600V
  - Max Current Output: 100A
  - Built in RS-232/RS-485 I/O Board
- Tempos Thermal Properties Analyzer (-50°C to 150°C)
- Hukseflux TP02 Thermal Properties Analyzer (-55°C to 180°C)
- Kurt J Lesker Thin Film Sputter Machine
  - Physical Vapor Deposition system with RF and DC target sputtering capability. 100mm tooling, heated substrate, load lock, film thickness monitor, substrate biasing.
- Axon MultiClamp 700B patch clamp amplifier on a vibration isolation table
  - Axon Digidata 1550 low-noise data acquisition system
  - o pClamp 10 electrophyisology data acquisition and analysis software